

Editorial

In recent issues of the Journal you will have noted that as and from 1st July 1997 the address for correspondence with the Journal has changed to the Dublin Institute of Technology at Bolton Street, Dublin 1, Ireland. The Institute welcomes the opportunity to become involved with the prestigious publication the International Journal of Engineering Education.

The Dublin Institute of Technology and TEMPUS publications have entered into a partnership agreement to host and support the Journal. Dr. Michael S. Wald will continue as Editor in charge and a new editorial structure is in place to reflect the partnership and the needs of the Journal.

The Dublin Institute of Technology is a comprehensive higher education institution, fulfilling a national and international role in providing full-time and part-time programmes across the whole spectrum of higher education. It aims to achieve this in an innovative responsive, caring and flexible learning environment. It is committed to providing access to students of all ages and backgrounds, and to achieving quality and excellence in all aspects of its work. This commitment extends to the provision of teaching, research, product development and consultancy services for industry and society, while continuing to have regard to the technological, commercial, social and cultural needs of the community it serves.

Engineering Education plays a very important role in the core activities of the Institute and our programme reflects the continuing development of Engineering Technology and Education. It was a logical development for the Faculty of Engineering to join with Tempus Publications in the production of the journal. The involvement of the Faculty with the journal will contribute to the development of the journal over the coming years. We are looking forward to interacting with you in the future and to receiving your comments and observations for the development of the journal.

We are aware of the importance of the task we are undertaking and we will endeavour to continue the high standards of the journal into the future.

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